EFS ID: 3215880 Application Number: 10815287 International Application Number: 8332 Title of Invention: Method of exposing layer with light and method of manufacturing thin film transistor substrate for liquid crytal display device using the same	Electronic Acknowledgement Receipt					
International Application Number: Confirmation Number: 8332 Method of exposing layer with light and method of manufacturing thin	EFS ID:	3215880				
Confirmation Number: 8332 Method of exposing layer with light and method of manufacturing thin	Application Number:	10815287				
Method of exposing layer with light and method of manufacturing thin	International Application Number:					
Title of Invention: Method of exposing layer with light and method of manufacturing thin film transistor substrate for liquid crytal display device using the same	Confirmation Number:	8332				
	Title of Invention:	Method of exposing layer with light and method of manufacturing thin film transistor substrate for liquid crytal display device using the same				
First Named Inventor/Applicant Name: Soon-II Ahn	First Named Inventor/Applicant Name:	Soon-II Ahn				
Customer Number: 22150	Customer Number:	22150				
Filer: Frank Chau	Filer:	Frank Chau				
Filer Authorized By:	Filer Authorized By:					
Attorney Docket Number: 8054-57 (LW9035US/KE)	Attorney Docket Number:	8054-57 (LW9035US/KE)				
Receipt Date: 28-APR-2008	Receipt Date:	28-APR-2008				
Filing Date: 01-APR-2004	Filing Date:	01-APR-2004				
Time Stamp: 12:12:17	Time Stamp:	12:12:17				
Application Type: Utility under 35 USC 111(a)	Application Type:	Utility under 35 USC 111(a)				
Payment information:	Payment information:					
Submitted with Payment no	· · · · · · · · · · · · · · · · · · ·	no				

File Listing:							
Document Number	Document Description	File Name	File Size(Bytes) /Message Digest	Multi Part /.zip	Pages (if appl.)		
	Amendment - After Non-Final	8054-57-amd.pdf	123260	no	12		
'	Rejection		59506a7a2402r208t Firelad79d79518a				

Warnings:

Information:

This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.

New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/IDO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filling Receipt, in due course.

New International Application Filed with the USPTO as a Receiving Office

If a new international application is being filed and the international application includes the necessary components for an international filing date (see PCT Article 11 and MPEP 1810), a Notification of the International Application Number and of the International Filing Date (Form PCT/RO/105) will be issued in due course, subject to prescriptions concerning national security, and the date shown on this Acknowledgement Receipt will establish the International filing date of the application.